

Title (en)

Process and plant for working a stone tile and tile thus obtained

Title (de)

Verfahren und Anlage zum Bearbeiten einer Steinfliese und so entstandene Fliese

Title (fr)

Procédé et installation pour le travail d'une dalle de pierre et dalle ainsi obtenue

Publication

**EP 2060362 A3 20100908 (EN)**

Application

**EP 08169051 A 20081113**

Priority

IT VR20070164 A 20071117

Abstract (en)

[origin: EP2060362A2] The present invention relates to a process for working a tile, which comprises the following steps in sequence: - arranging a work piece having a flat work or open face (SP); - applying at least one coating or masking layer (5a, 5b) onto at least one portion of the work face (SL), thereby obtaining a work face having at least one coated or masked area (3a) and at least one uncovered or free area (3b); and - carrying out at least one finishing operation on the work face by means of at least one working tool, whereby processing the at least one uncovered or free area (3b) of the work face (SL), whereas the at least one coating layer prevents the at least one working tool from processing or thoroughly processing the at least one coated or masked area.

IPC 8 full level

**B24B 7/19** (2006.01); **B24B 29/02** (2006.01); **B24C 1/04** (2006.01); **B44C 1/22** (2006.01)

CPC (source: EP)

**B24B 7/19** (2013.01); **B24B 29/005** (2013.01); **B24B 29/02** (2013.01); **B44C 1/005** (2013.01); **B44C 1/222** (2013.01); **B44C 5/0438** (2013.01);  
**B44C 5/0461** (2013.01)

Citation (search report)

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Designated contracting state (EPC)

AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HR HU IE IS IT LI LT LU LV MC MT NL NO PL PT RO SE SI SK TR

Designated extension state (EPC)

AL BA MK RS

DOCDB simple family (publication)

**EP 2060362 A2 20090520**; **EP 2060362 A3 20100908**; BR PI0805138 A2 20091201; CN 101434101 A 20090520; IT VR20070164 A1 20090518;  
RU 2008145025 A 20100520

DOCDB simple family (application)

**EP 08169051 A 20081113**; BR PI0805138 A 20081114; CN 200810176523 A 20081117; IT VR20070164 A 20071117;  
RU 2008145025 A 20081114